



Docket No.: SON-2769

(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of: Hidetoshi OHNUMA, et al

Application No.: 10/603,689

Filed: June 26, 2003

For: EXPOSURE METHOD, MASK

FABRICATION METHOD, FABRICATION METHOD OF SEMICONDUCTOR DEVICE

AND EXPOSURE APPARATUS

Confirmation No.: 2872

Art Unit: 1756

Examiner: D. D. Chacko

RESPONSE TO FINAL OFFICE ACTION

MS AF Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

INTRODUCTORY COMMENTS

This is in response to the Office Action dated July 25, 2006.

Remarks/Arguments begin on page 2 of this paper.